

AMENDMENT TO THE SPECIFICATION

Please replace paragraph [0012] with the following replacement paragraph:

[0012] The layer of gold typically has thickness of from 10 to 1000 nm, alternatively from 25 to 500 nm, alternatively ~~from~~ from 50 to 200 nm. Methods of depositing gold are well known in the art. For example, the layer of gold can be deposited on a surface of the mold by physical vapor deposition (PVD) methods, including thermal evaporation, DC magnetron sputtering, and RF sputtering.